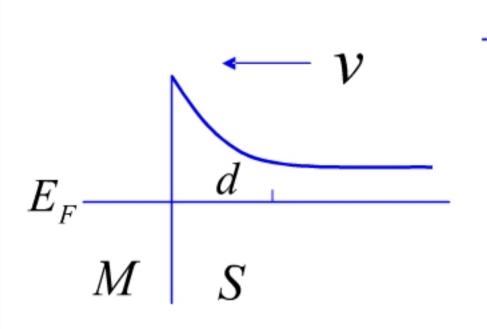
### 9.2.2 热电子发射理论



一适用于势垒宽度<<电子平均自由程  $l_n >> d$ 

$$E - E_C = \frac{m_n^*}{2} \left( v_x^2 + v_y^2 + v_z^2 \right) = \frac{1}{2m_n^*} \left( P_x^2 + P_y^2 + P_z^2 \right)$$

单位动量空间
$$dP_x dP_y dP_z$$
中的状态数
$$2\frac{V}{(2\pi)^3}dk_x dk_y dk_z = \frac{2V}{\hbar^3(2\pi)^3}dP_x dP_y dP_z = \frac{2V}{\hbar^3}dP_x dP_y dP_z$$

实空间单位体积中,动量空间单位体积 $dP_x dP_y dP_z$ 中的电子数

$$dn' = \frac{2dP_{x}dP_{y}dP_{z}}{h^{3}} \exp\left(-\frac{E - E_{F}}{kT}\right) = \frac{2dP_{x}dP_{y}dP_{z}}{h^{3}} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{2kT}\right] \exp\left(-\frac{E_{C} - E_{F}}{kT}\right)$$

$$= \frac{2m_{n}^{*3}}{h^{3}} \exp\left(-\frac{E_{C} - E_{F}}{kT}\right) \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{2kT}\right] dv_{x} dv_{y} dv_{z}$$

$$= n_{0} \left(\frac{m_{n}^{*}}{2\pi kT}\right)^{3/2} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{2kT}\right] dv_{x} dv_{y} dv_{z}$$

$$= n_{0} \left(\frac{m_{n}^{*}}{2\pi kT}\right)^{3/2} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{2kT}\right] dv_{x} dv_{y} dv_{z}$$

$$\frac{n_{0} = 2\frac{\left(2\pi m_{n}^{*}kT\right)^{\frac{3}{2}}}{h^{3}} \exp\left(-\frac{E_{c} - E_{F}}{kT}\right)$$

$$\frac{1}{2kT} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{2kT}\right] dv_{x} dv_{y} dv_{z}$$

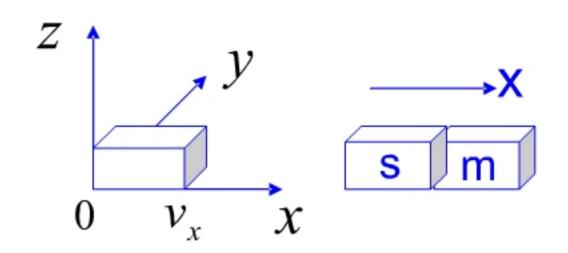
$$\frac{1}{2kT} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{h^{3}}\right] dv_{x} dv_{y} dv_{z}$$

$$\frac{1}{2kT} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{h^{3}}\right] dv_{x} dv_{y} dv_{z}$$

$$\frac{1}{2kT} \exp\left[-\frac{m_{n}^{*}\left(v_{x}^{2} + v_{y}^{2} + v_{z}^{2}\right)}{h^{3}}\right] dv_{x} dv_{y} dv_{z}$$

#### 9.2.2 热电子发射理论

实空间单位体积,速度空间电子的分布
$$dn' = n_0 \left( \frac{m_n^*}{2\pi kT} \right)^{3/2} \exp \left[ -\frac{m_n^* \left( v_x^2 + v_y^2 + v_z^2 \right)}{2kT} \right] dv_x dv_y dv_z$$



 $l_n >> d$ 

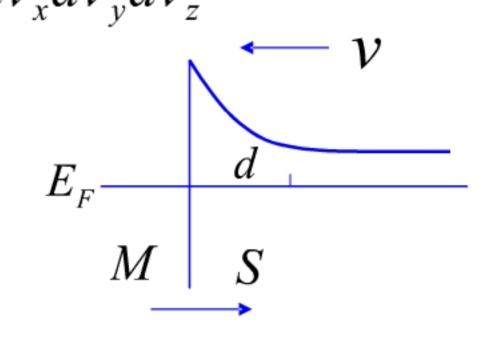
实空间单位面积,单位时间,速度v<sub>x</sub>(>0)的电子都可以到达金半界面,其数目为

$$dN = n_0 \left( \frac{m_n^*}{2\pi kT} \right)$$

$$dN = n_0 \left(\frac{m_n^*}{2\pi kT}\right)^{3/2} \exp\left[-\frac{m_n^* (v_x^2 + v_y^2 + v_z^2)}{2kT}\right] v_x dv_x dv_y dv_z$$

可以越过势垒电

可以越过势垒电  
子的能量要求 
$$\frac{1}{2}m_n^*v_{x0}^2 = q(V_D - V)$$



 $V_x$  积分限:  $V_{x0} \rightarrow +\infty$  电流密度

$$V_y$$
 积分限:  $-\infty \to +\infty$ 

$$V_z$$
 积分限:  $-\infty \to +\infty$ 

$$J_{s\to m} = \iiint n_0 \left(\frac{m_n^*}{2\pi kT}\right)^{3/2} \exp\left[-\frac{m_n^*(v_x^2 + v_y^2 + v_z^2)}{2kT}\right] \cdot qv_x dv_y dv_z$$

### 9.2.2 热电子发射理论

$$J_{s\to m} = \iiint n_0 \left(\frac{m_n^*}{2\pi kT}\right)^{3/2} \exp\left[-\frac{m_n^* \left(v_x^2 + v_y^2 + v_z^2\right)}{2kT}\right] \cdot qv_x dv_x dv_y dv_z$$

$$v_x : v_{x0} \to +\infty; \quad v_y : -\infty \to +\infty; \quad v_z : -\infty \to +\infty$$

$$= qn_0 \left(\frac{kT}{2\pi m_n^*}\right)^{1/2} \exp\left(-m_n^* v_{x0}^2 / 2kT\right), \qquad E_F$$

$$M \quad S$$

$$= \frac{4\pi q m_n^* k^2}{h^3} T^2 \exp\left(-q \phi_{ns} / kT\right) \exp\left(qV / kT\right)$$

$$\frac{1}{2} m_n^* v_{x0}^2 = q(V_D - V)$$

$$= A^*T^2 \exp(-q\phi_{ns}/kT) \exp(qV/kT)$$

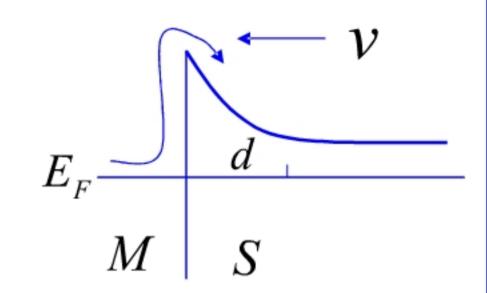
一半导体到金属的电子流 依赖于电压

 $A^* = 120 (m_n^*/m_0) [Acm^{-2}K^{-2}]$ 

### 9.2.2 热电子发射理论

一金属到半导体的电子流基本不依赖于电压

$$J_{m o s}$$
: 常数

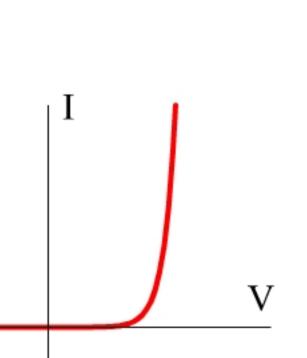


$$V = 0$$
,  $J = 0$   $J =$ 

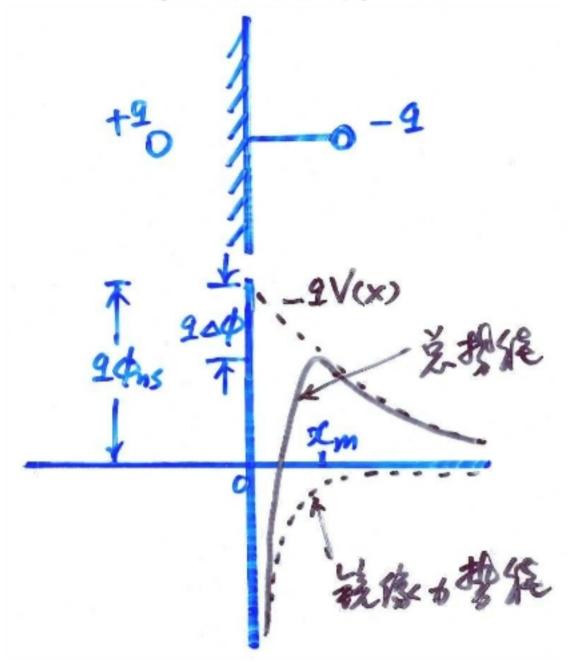
$$J(V) = J_{s \to m}(V) + J_{m \to s}^{\downarrow}(0)$$

$$= A^*T^2 \exp(-q\phi_{ns}/kT) \left[\exp(qV/kT) - 1\right]$$

$$= J_{ST} \left[ \exp(qV/kT) - 1 \right]$$



### 9.2.3 镜像力影响



$$f_{im} = -\frac{q^2}{4\pi\varepsilon_0\varepsilon_r(2x)^2}$$

$$U_{im}(x) = \int_x^\infty f_{im} dx = -\frac{q^2}{16\pi\varepsilon_0\varepsilon_r x}$$

$$V(x) = -\frac{qN_D}{2\varepsilon_0\varepsilon_r} (x^2 - 2xd) - \phi_{ns}$$
电子总电势能
$$U(x) = -\frac{q^2}{16\pi\varepsilon_0\varepsilon_r x} - qV(x)$$

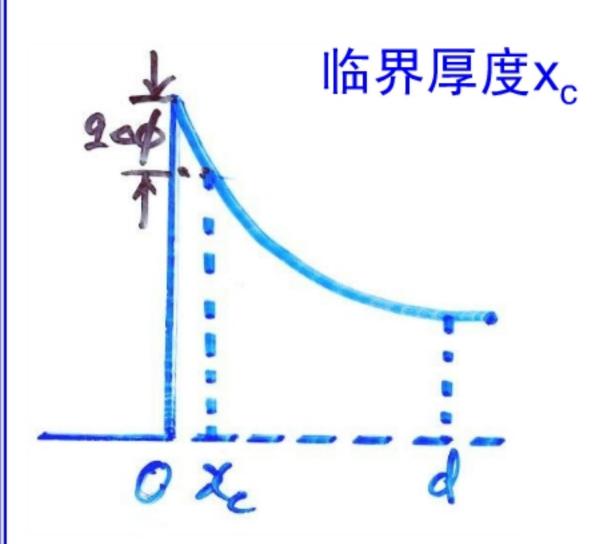
$$U(x) = -\frac{q^2}{16\pi\varepsilon_0\varepsilon_r x} - qV(x)$$

$$\frac{dU(x)}{dx}\Big|_{x=x_m} = 0 \qquad x_m << d$$

$$x_m = (4\pi N_D d)^{-1/2}$$

$$q\Delta\phi = \frac{q^2N_D}{\varepsilon_0\varepsilon_r}x_m d = \frac{1}{4}\left[\frac{2q^7N_D}{\pi^2\varepsilon_0^3\varepsilon_r^3}(V_D - V)\right]^{1/4} - qV(x_m) = q\phi_{ns} - \frac{q^2N_D}{\varepsilon_0\varepsilon_r}x_m d$$

#### 9.2.4 隧道效应影响



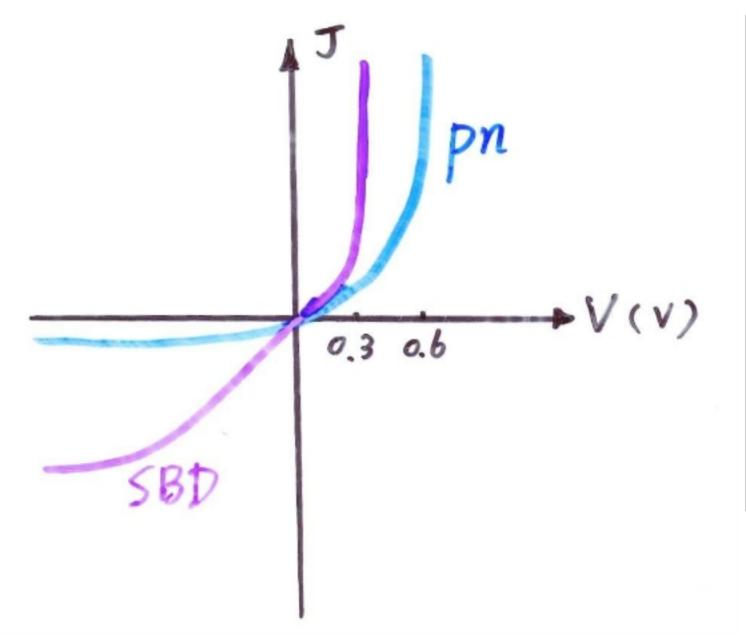
$$-qV(x_c) = -q \left[ \frac{qN_D}{\varepsilon_0 \varepsilon_r} \left( x_c d - \frac{x_c^2}{2} \right) - \phi_{ns} \right]$$

$$x_c \ll d$$

$$-qV(x_c) \approx q\phi_{ns} - \left[\frac{2q^3N_D}{\varepsilon_0\varepsilon_r}(V_D - V)\right]^{1/2} x_c$$

$$q\Delta\phi = \left[\frac{2q^3N_D}{\varepsilon_0\varepsilon_r}(V_D - V)\right]^{1/2} x_c$$

### 9.2.5 pn结和肖特基势垒二极管



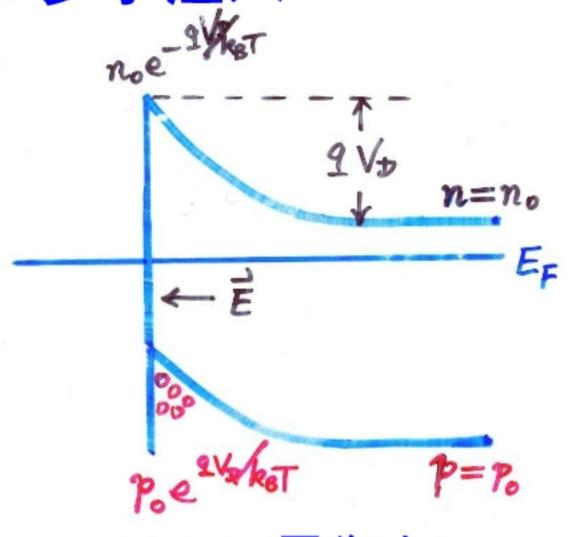
pn	SBD
少子器件,	多子器件,
电荷存贮效应	载流子无存贮
低频	高频
导通电压~0.6	导通电压~0.3
V	V

# 第九章金半接触

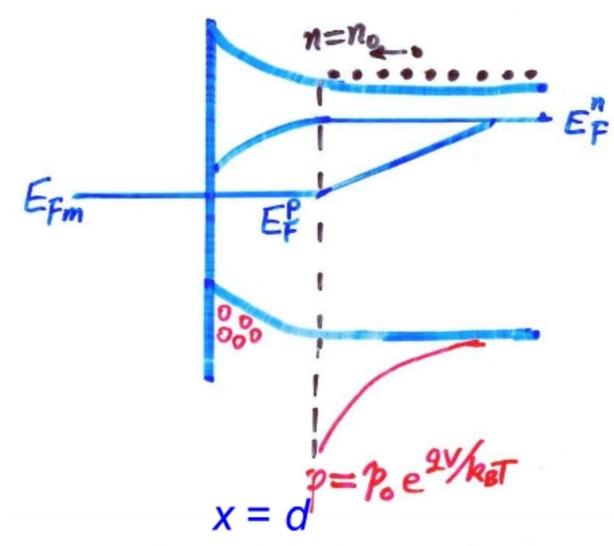
- 9.1 金半接触的能带图
- 9.2 金半接触的整流输运理论
- 9.3 少子注入和欧姆接触

# 9.3 少子注入和欧姆接触1

### 9.3.1 少子注入



V = 0 (平衡态) 空穴扩散与电场抵消

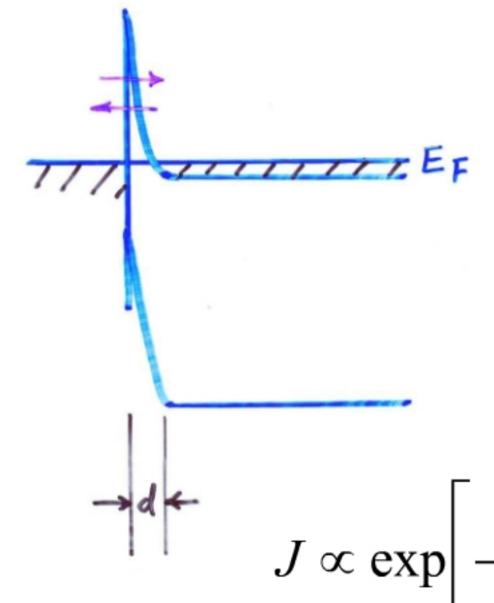


V>0(正偏) 空穴扩散主导

$$\gamma = \frac{J_p}{J} = \frac{J_p}{J_n + J_p}$$

# 9.3 少子注入和欧姆接触2

### 9.3.2 欧姆接触



金属一重掺杂半导体接触

$$N_D = 10^{19} \text{ cm}^{-3} d \sim 10^2 \text{ Å}$$

电子隧穿通过势垒区

$$J_{s\to m} \propto \exp \left[ -\frac{4\pi}{h} \left( \frac{m_n^* \varepsilon_0 \varepsilon_r}{N_D} \right)^{1/2} (V_D - V) \right]$$

$$J_{m\to s} = C \equiv J_{m\to s}|_{V=0\,V} = J_{s\to m}|_{V=0\,V}$$

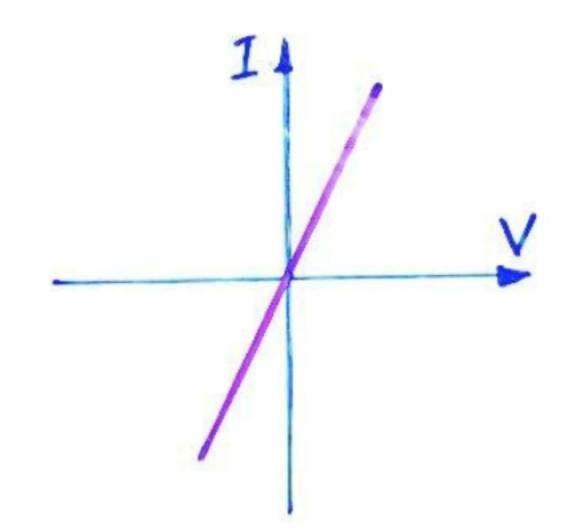
$$J \propto \exp \left[ -\frac{4\pi}{h} \left( \frac{m_n^* \varepsilon_0 \varepsilon_r}{N_D} \right)^{1/2} V_D \right] \left\{ \exp \left[ \frac{4\pi}{h} \left( \frac{m_n^* \varepsilon_0 \varepsilon_r}{N_D} \right)^{1/2} V \right] - 1 \right\}$$

$$N_{D} >> 1 \longrightarrow J \propto \frac{4\pi}{h} \left(\frac{m_{n}^{*} \varepsilon_{0} \varepsilon_{r}}{N_{D}}\right)^{1/2} \exp \left[-\frac{4\pi}{h} \left(\frac{m_{n}^{*} \varepsilon_{0} \varepsilon_{r}}{N_{D}}\right)^{1/2} V_{D}\right] \cdot V$$

# 9.3 少子注入和欧姆接触3

### 9.3.2 欧姆接触

$$J \propto \frac{4\pi}{h} \left( \frac{m_n^* \varepsilon_0 \varepsilon_r}{N_D} \right)^{1/2} \exp \left[ -\frac{4\pi}{h} \left( \frac{m_n^* \varepsilon_0 \varepsilon_r}{N_D} \right)^{1/2} V_D \right] \cdot V \propto V$$



1°线性 I-V, 正反向对称

2° 
$$R = \left(\frac{dI}{dV}\right)^{-1}$$
 接触电阻很小